

PATENT 30205/37777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jae Chang Jung et al.) I hereby certify that this paper and the documents referred to as enclosed
Serial No.: 10/054,095	therewith are being deposited with the United States Postal Service as first class
Filed: January 22, 2002	mail, postage prepaid, on February 19,2004, in an envelope addressed to
For: Chemical Amplification) Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450
Photoresist Monomers, Polymers	
Therefrom and Photoresist	$\langle \rangle$
Compositions Containing the Same	$\beta = \beta \beta$
Group Art Unit: 1752) Michael R. Hull Reg. No. 35,902
Examiner: Rosemary E. Ashton	Attorney for Applicants

COMMENT ON STATEMENT OF REASONS FOR ALLOWANCE

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

In addition to the reasons for allowance set forth in the allowance papers that were mailed in connection with the present application, it is respectfully submitted that the claims are allowable for the additional reasons that the invention defined by the language of the claims is neither anticipated by, nor would have been obvious when taken as a whole in view of, the art of record.

Respectfully submitted,

MARSHALL, GERSTEIN & BORUN LLP

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233 South Wacker Drive

Chicago, Illinois 60606-6357

(312) 474-9577

February 19, 2004

By:

Mickael R. Hull Reg. No. 35,902



PATENT 30205/38008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Hyung Hwan Kim and) Sang Ick Lee)	I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the
Serial No.: 10/053,565	United States Postal Service as first class mail, postage prepaid, on February 19,
Filed: January 22, 2002	2004, in an envelope addressed to Commissioner for Patents, P.O. Box
For: Nitride CMP Slurry Having) Selectivity to Nitride)	1450, Alexandria, Virginia 22313-1450
Group Art Unit: 3723	Missack Hull
Examiner: George Binh Minh Nguyen	Reg. No. 35,902 Attorney for Applicants

COMMENT ON STATEMENT OF REASONS FOR/ALLOWANCE

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